

2/28 @Hamamatsu



# The effect of the thickness of alumina adhesion to the collection plate on aluminum precipitation

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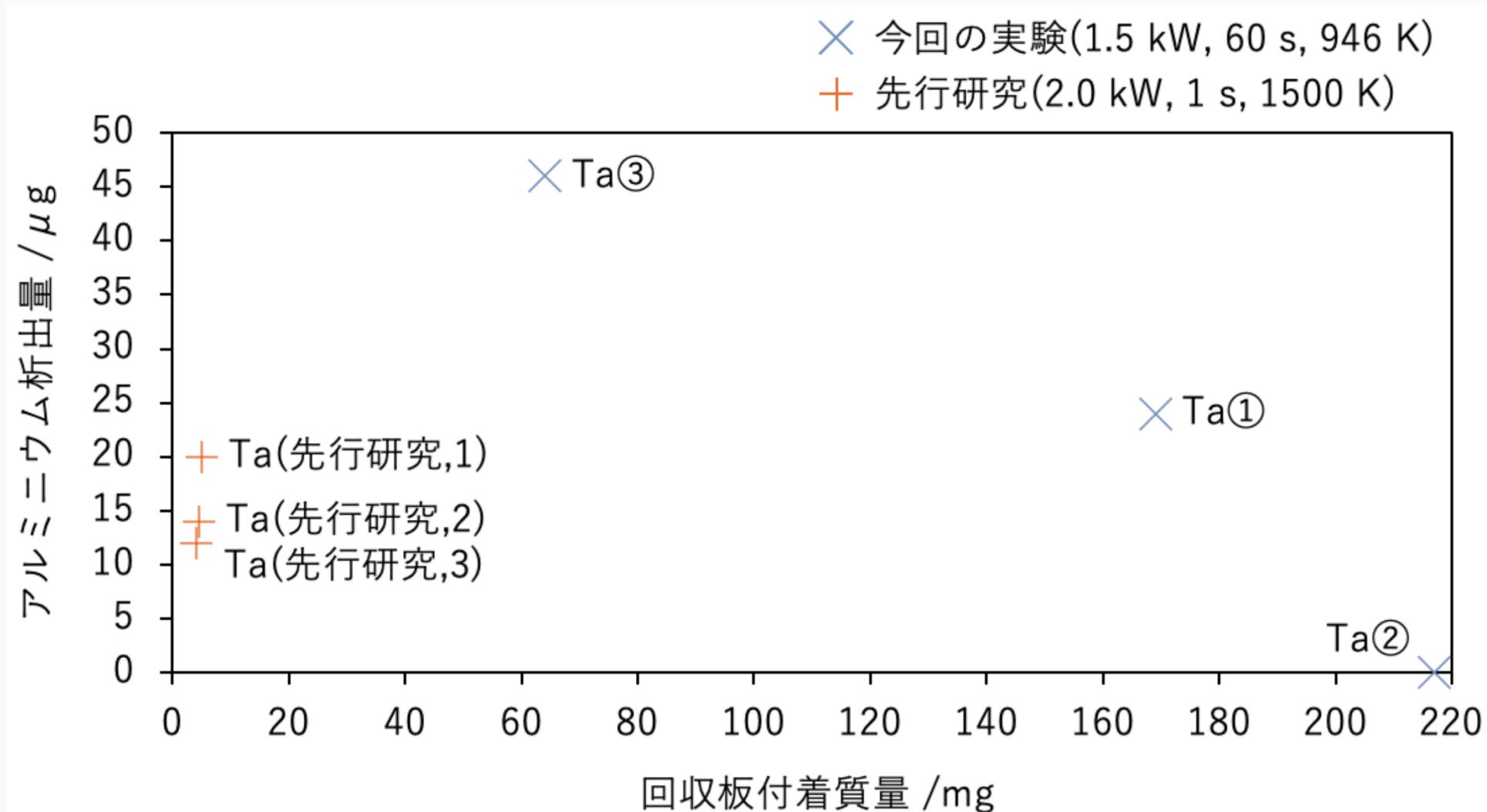
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## 3 experiments with ~1000 K Ta plates were conducted

- 2 of 3 experiments confirmed the existence of Al, **24  $\mu\text{g}$** , **46  $\mu\text{g}$**  respectively
- High adhesion mass(**64~217 mg**) & Thick adhesion layer(**0.68 mm ~**) were achieved



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# Contents

- 01 - Introduction
  - 02 - Method
  - 03 - Results & Discussion
  - 04 - Conclusion & Future work
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01

# Introduction

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- Backgrounds
- Previous study
- Objective
- Review of Last Lab Seminar
- Summary of introduction

01

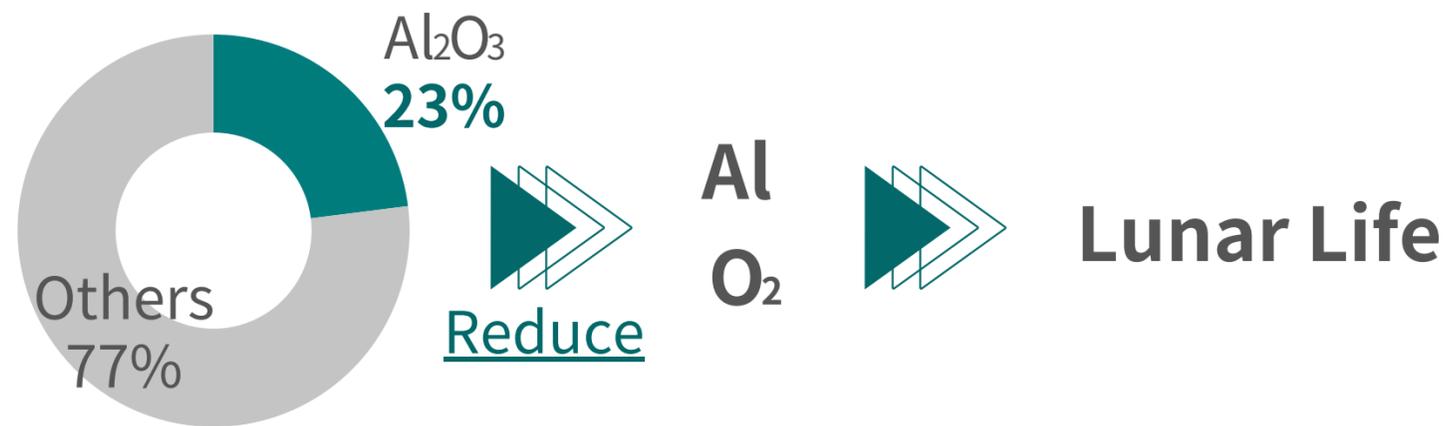


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## Regolith reduction for ISRU

- Regolith reduction helps to realize lunar life



Regolith composition

- For lunar base, **In-situ resource utilization (ISRU)** is indispensable

**10 million yen/kg (Earth→Moon)**

## CW laser ablation

- Thermally dissociate and reduce alumina by laser



**ISRU**



**Middle energy efficiency**

- **CW laser is superior** in terms of practical application



**Large ablation mass**

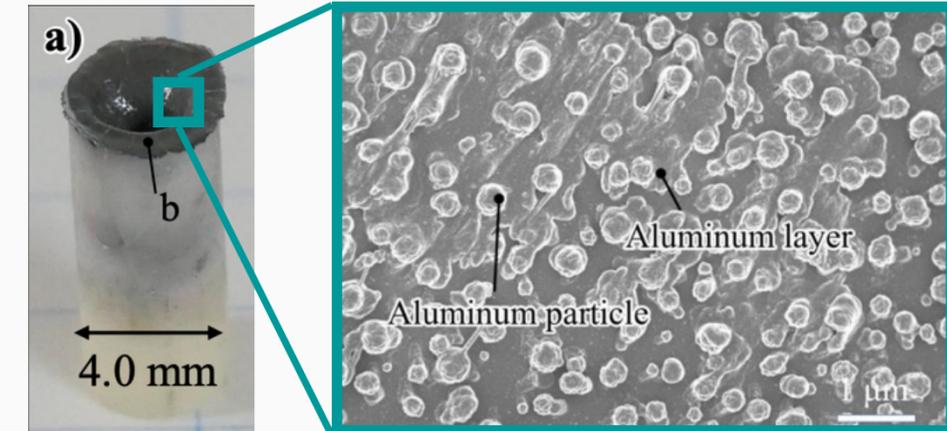


**Low Al collection rate**

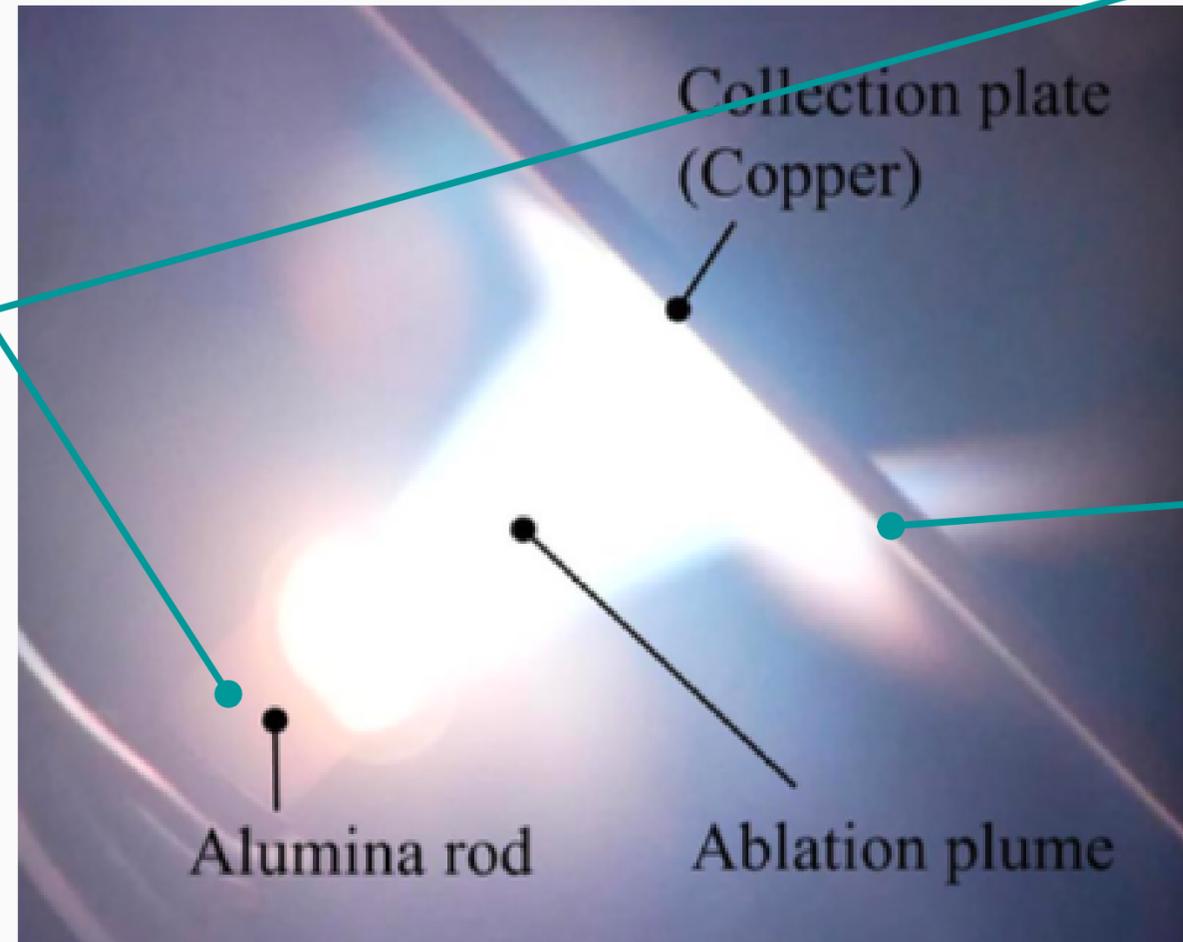
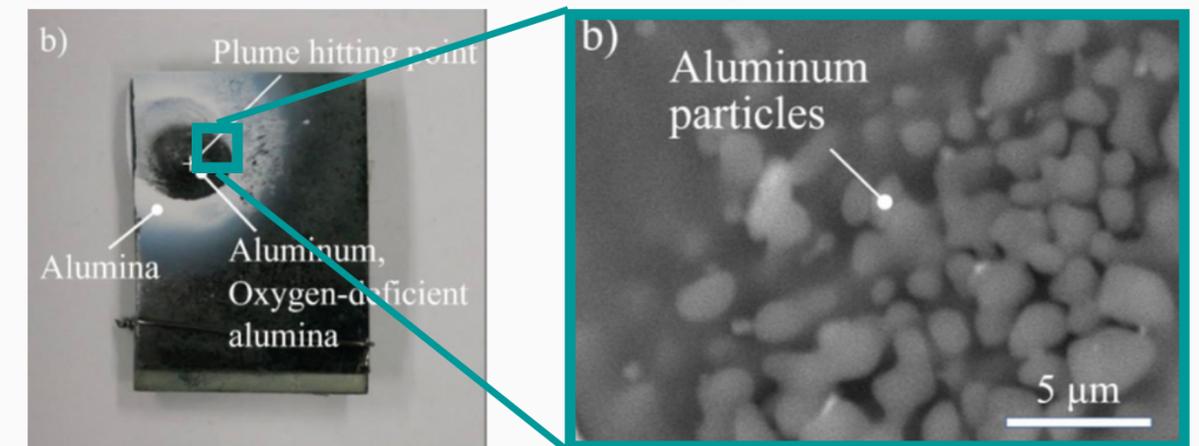
# High Al mass on the plate hasn't been achieved Previous study

## 2 types of Al collection

1. On the rod (Al:  $14 \mu\text{g}$  @  $1.5 \text{ kW}/1 \text{ s}$ )



2. On the plate (Al:  $110 \mu\text{g}$  @  $2 \text{ kW}/1 \text{ s}$ ).



▶▶ Plate collection is superior in the terms of Aluminum mass

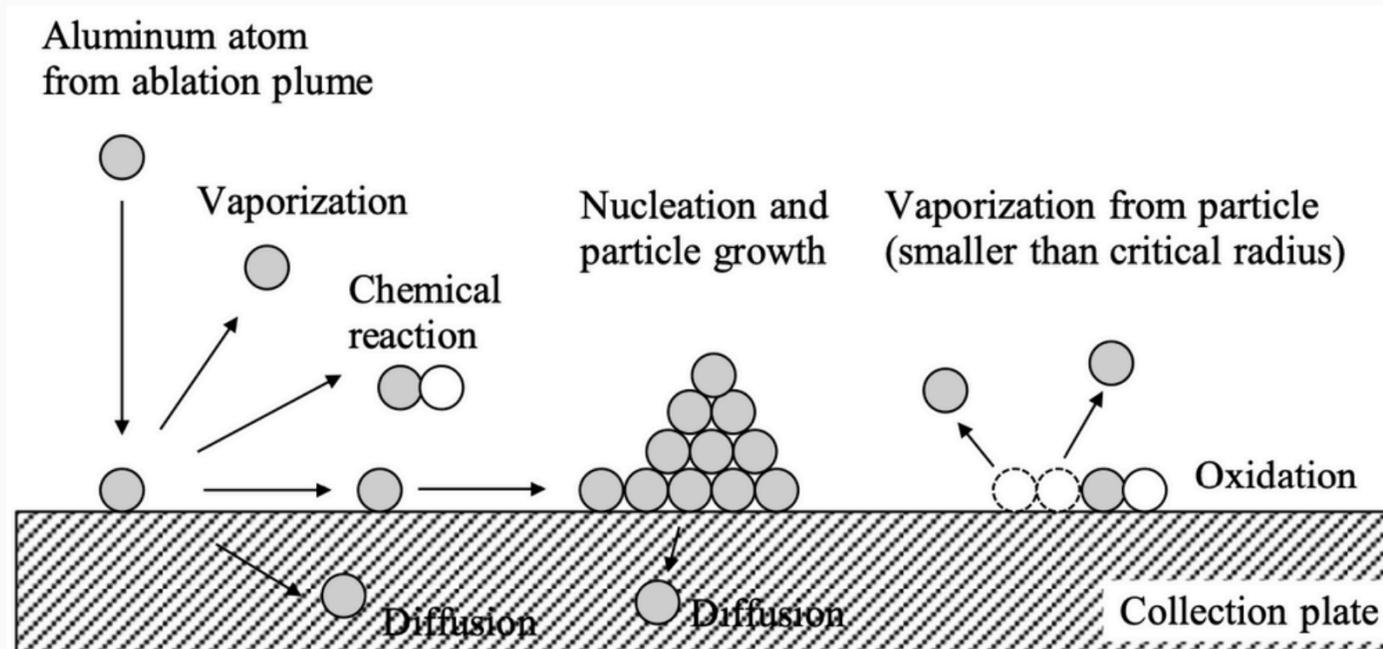
▶▶ The Al collection mass is not enough for the practical use

# Thickness of $\text{Al}_2\text{O}_x$ layer is a key for Al reduction

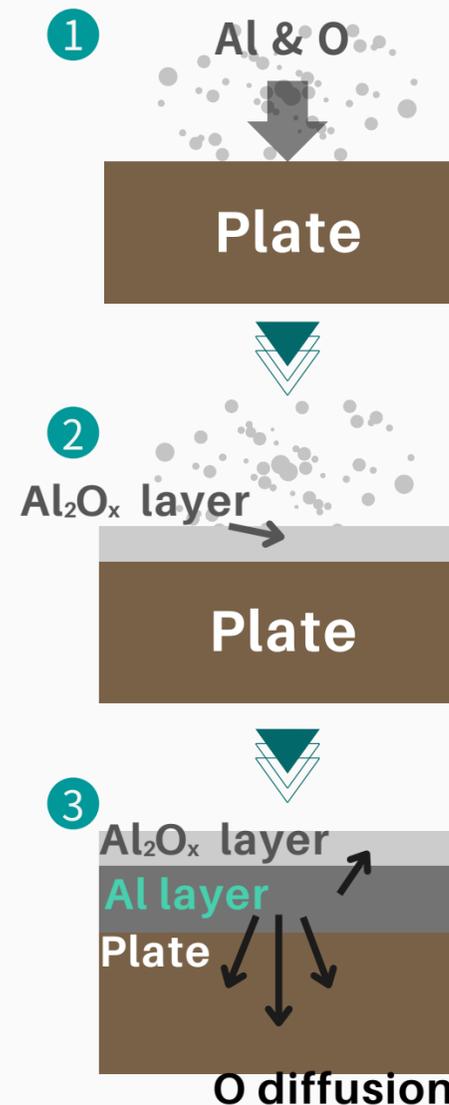
Objective

## What happens on the plate?

- Reflection, vaporization, recombination & atomic diffusion



## Mechanism of Al precipitation<sup>1</sup>



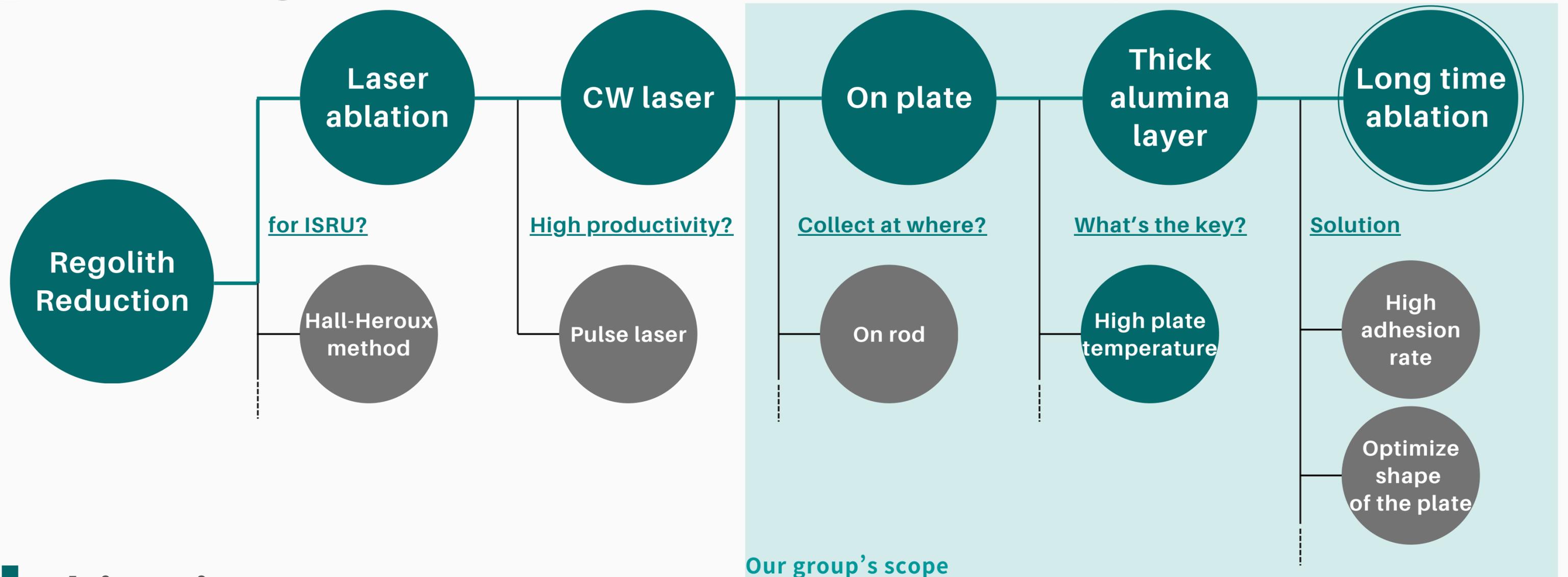
- Separated Al & O reaches the plate

- Form an oxygen-deficient alumina layer

- O atoms in the middle diffuse to the plate & the surface
- High plate temperature encourages the diffusion

▶ Encouraging O atoms diffusion by thick  $\text{Al}_2\text{O}_x$  layer (& high plate T)  
→ Long ablation (& preheating the plate) is a way

## Increasing adhesion rate on plate is the key for Al collection



## objective

- Increasing the thickness of  $Al_2O_x$  layer by long time ablation

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02

# Methods

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- Setup & condition
- Experiment procedure
- Analysis method

02

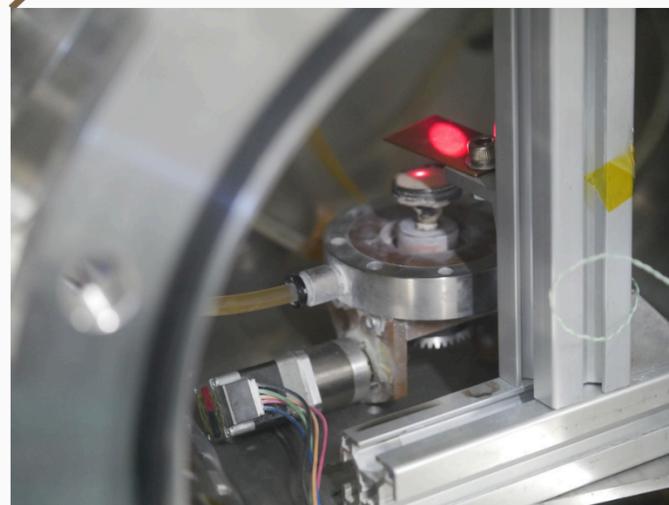
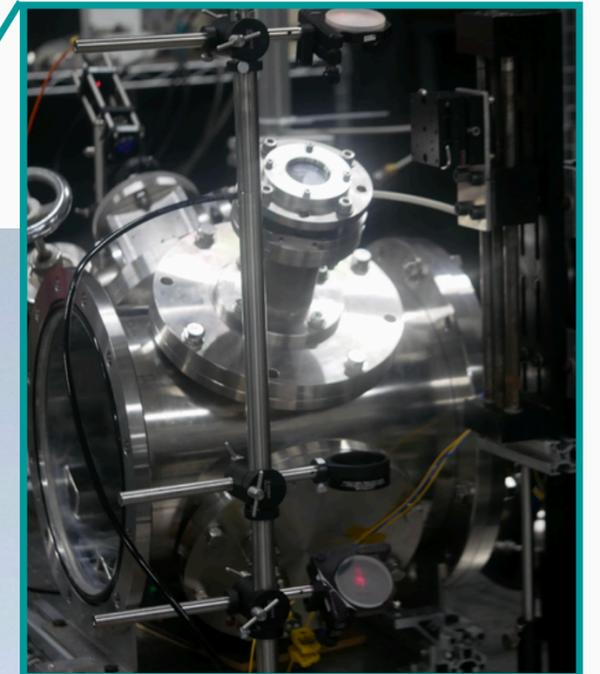
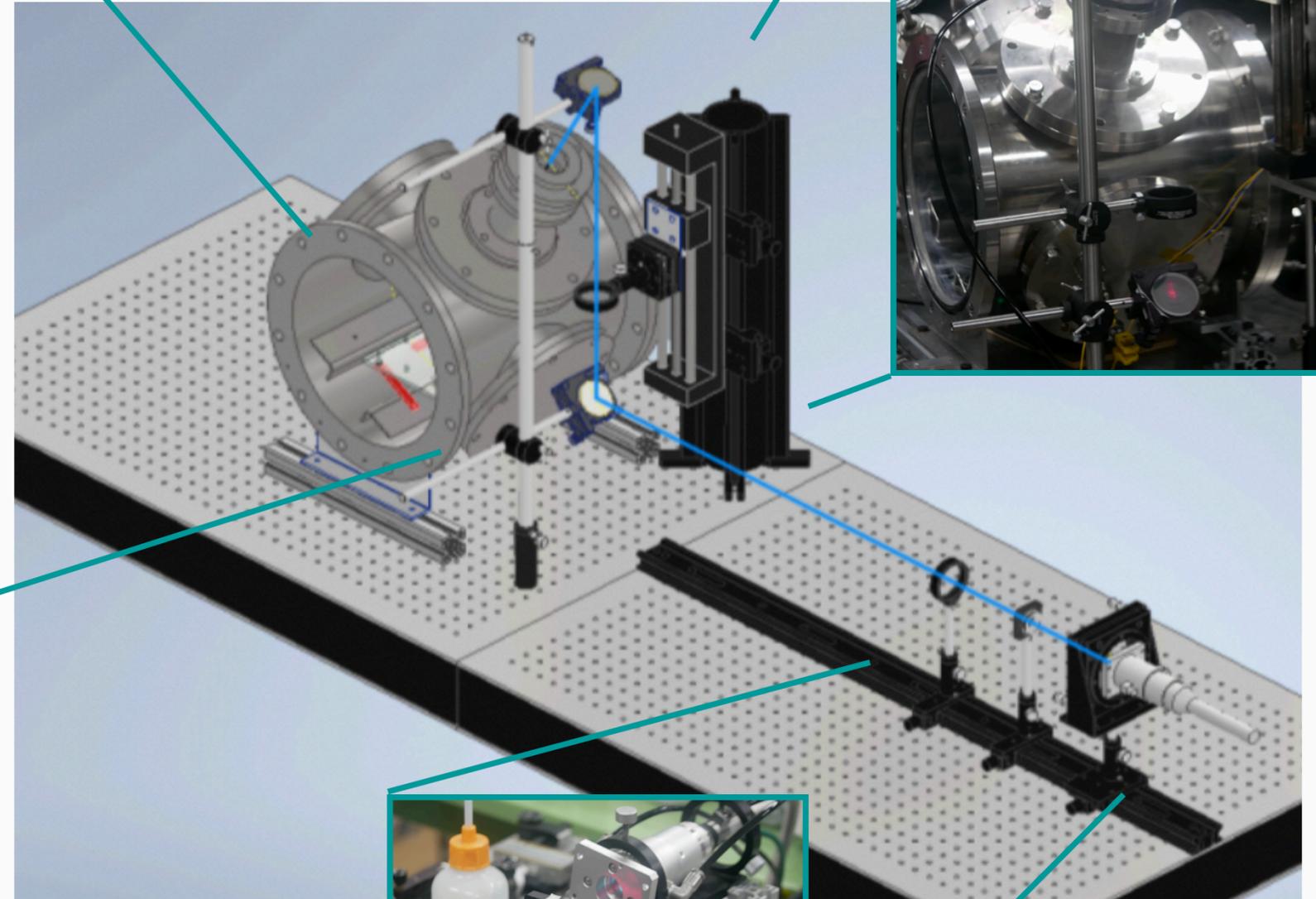
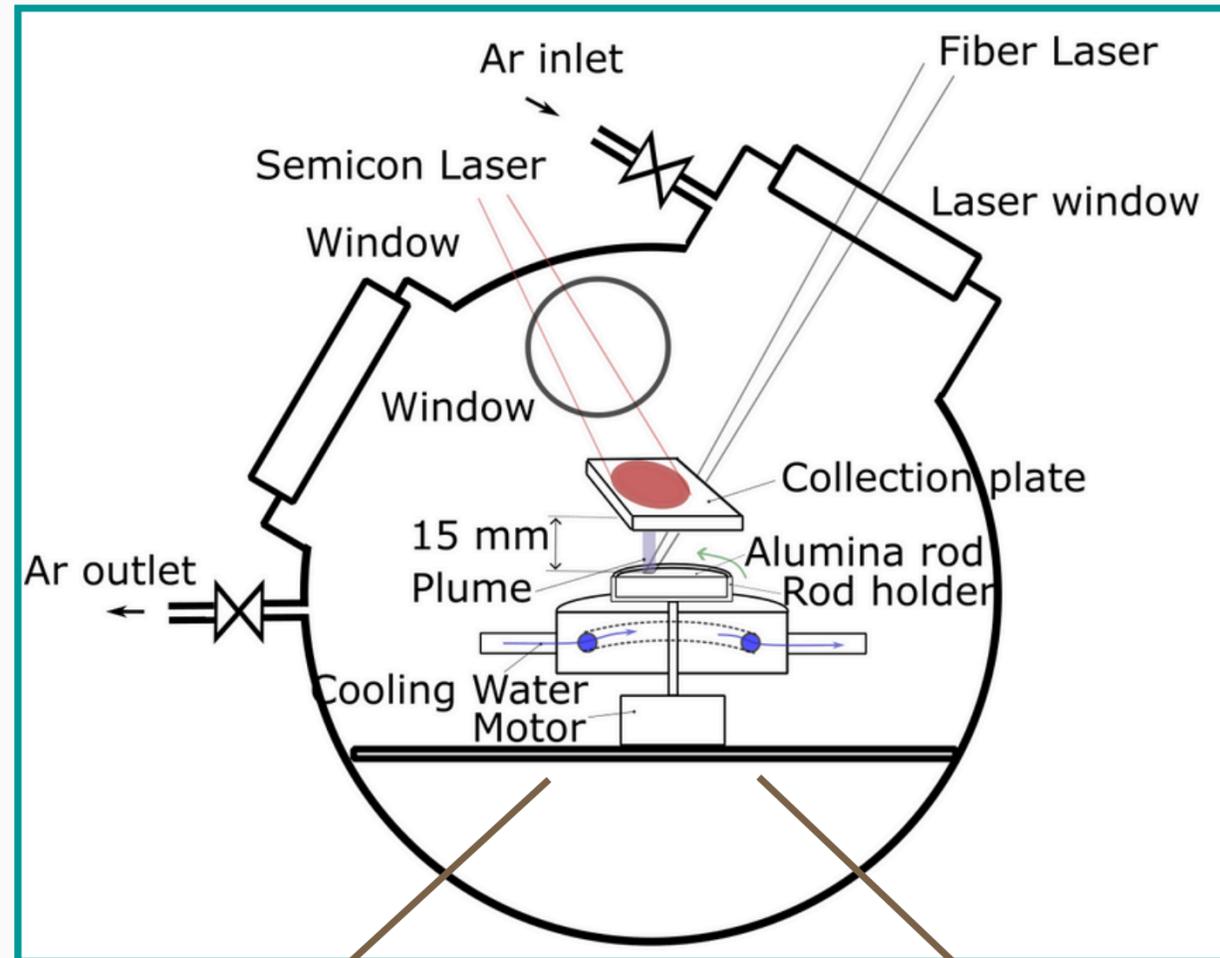


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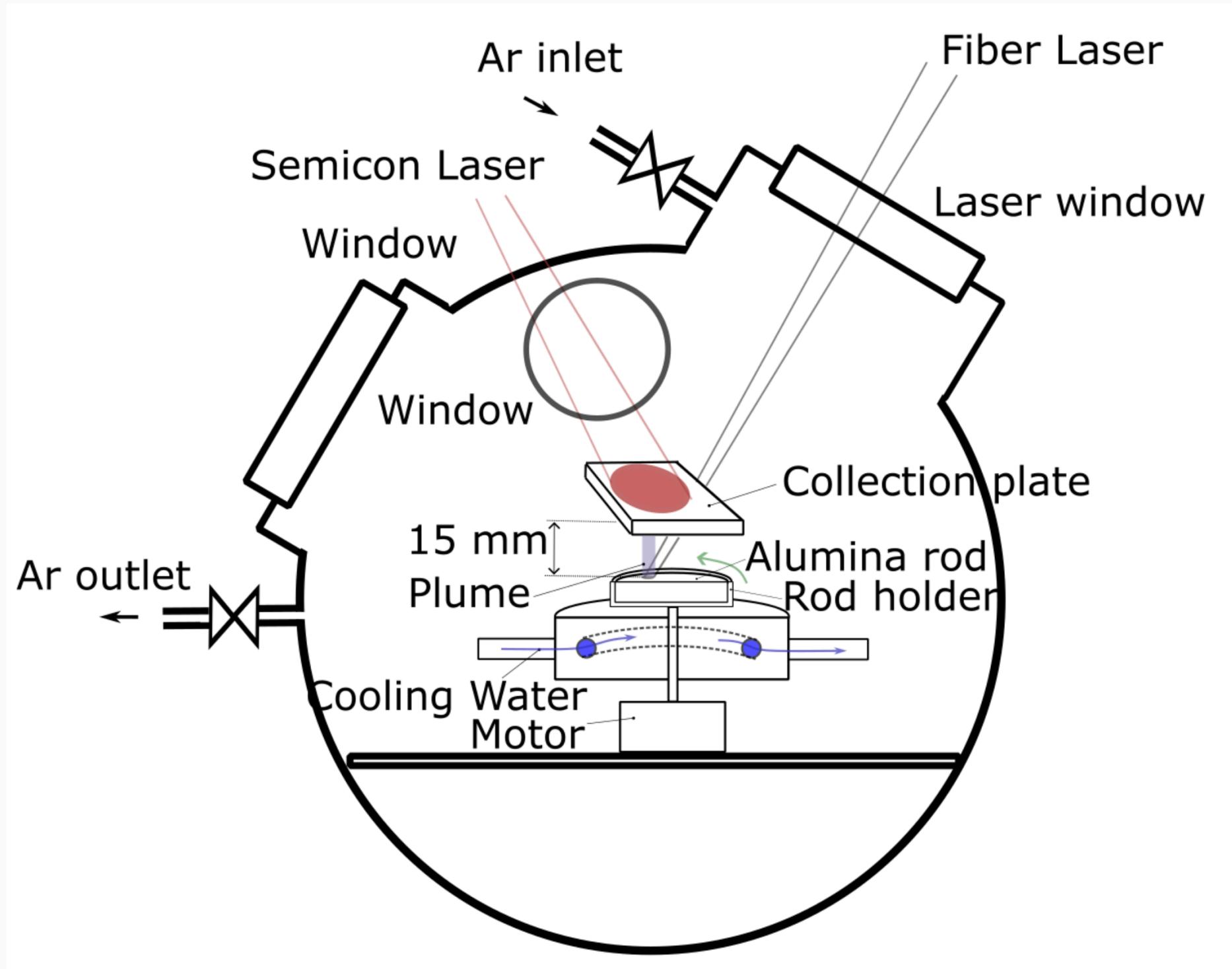
# Overview of experimental set up

Setup & condition



# Set up detail & condition

Setup & condition



## Rotating Alumina rod

- $\phi 20$  mm
- 5 mm thickness
- 1 rpm

## Collection plate

- Tantal
- 20 mm  $\times$  50 mm

## Atmosphere

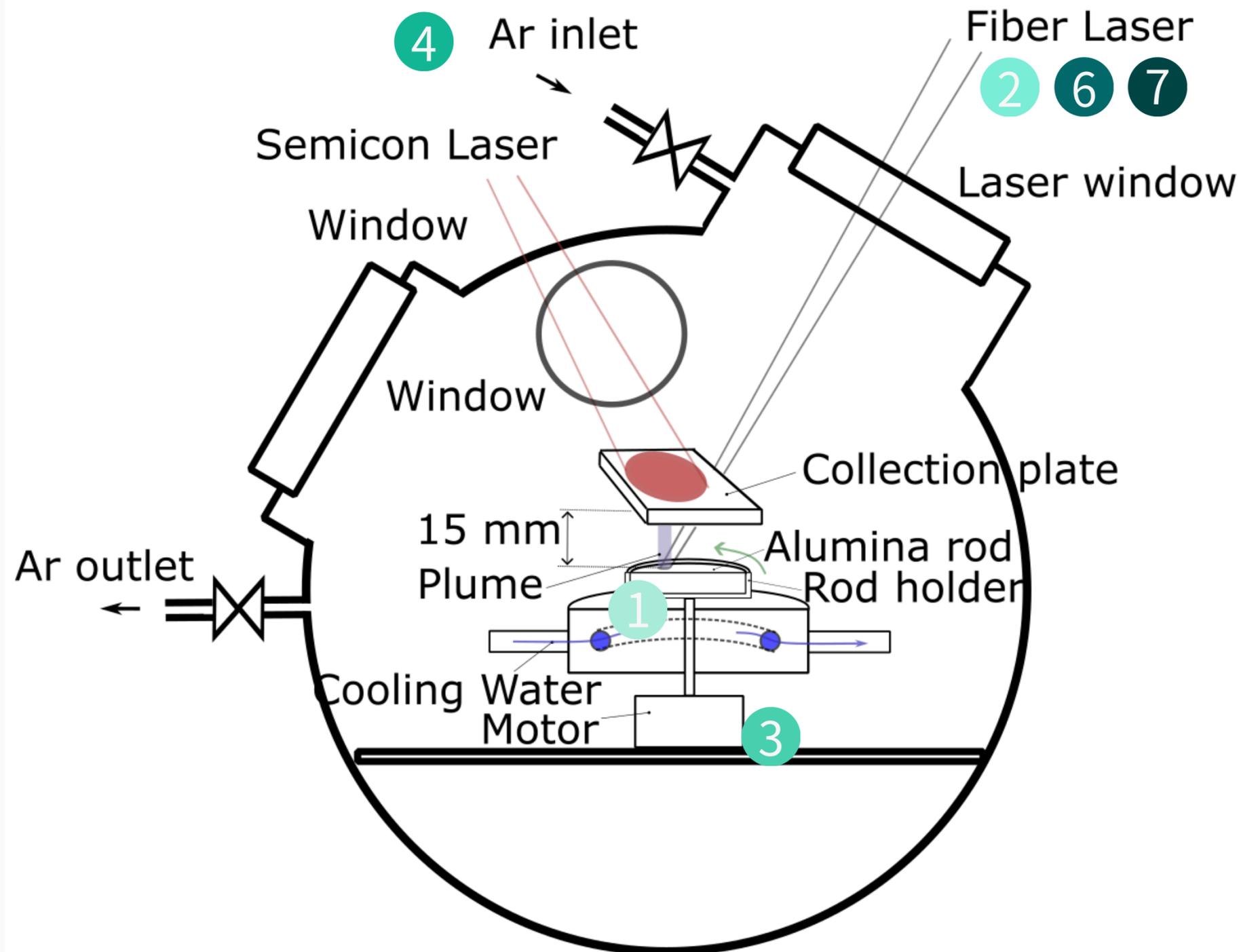
- Ar
- 1 atm

## CW laser

- 1.5 kW,  $\phi 2.2$  mm
- 10%, 3 min(preheat)
- 100%, 60 s(ablate)

# Experiment procedure

## Experiment procedure



- 1 Fix the Rod & the plate
- 2 Align the laser
- 3 Activate the motor
- 4 Evacuate & inlet Ar
- 5 Start recording
- 6 Turn on the laser
- 7 Stop the laser

# Several data was collected

Analysis method



Collection plate

Adhesion mass



H<sub>2</sub> detection



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03

# Results & Discussion

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- Results

03

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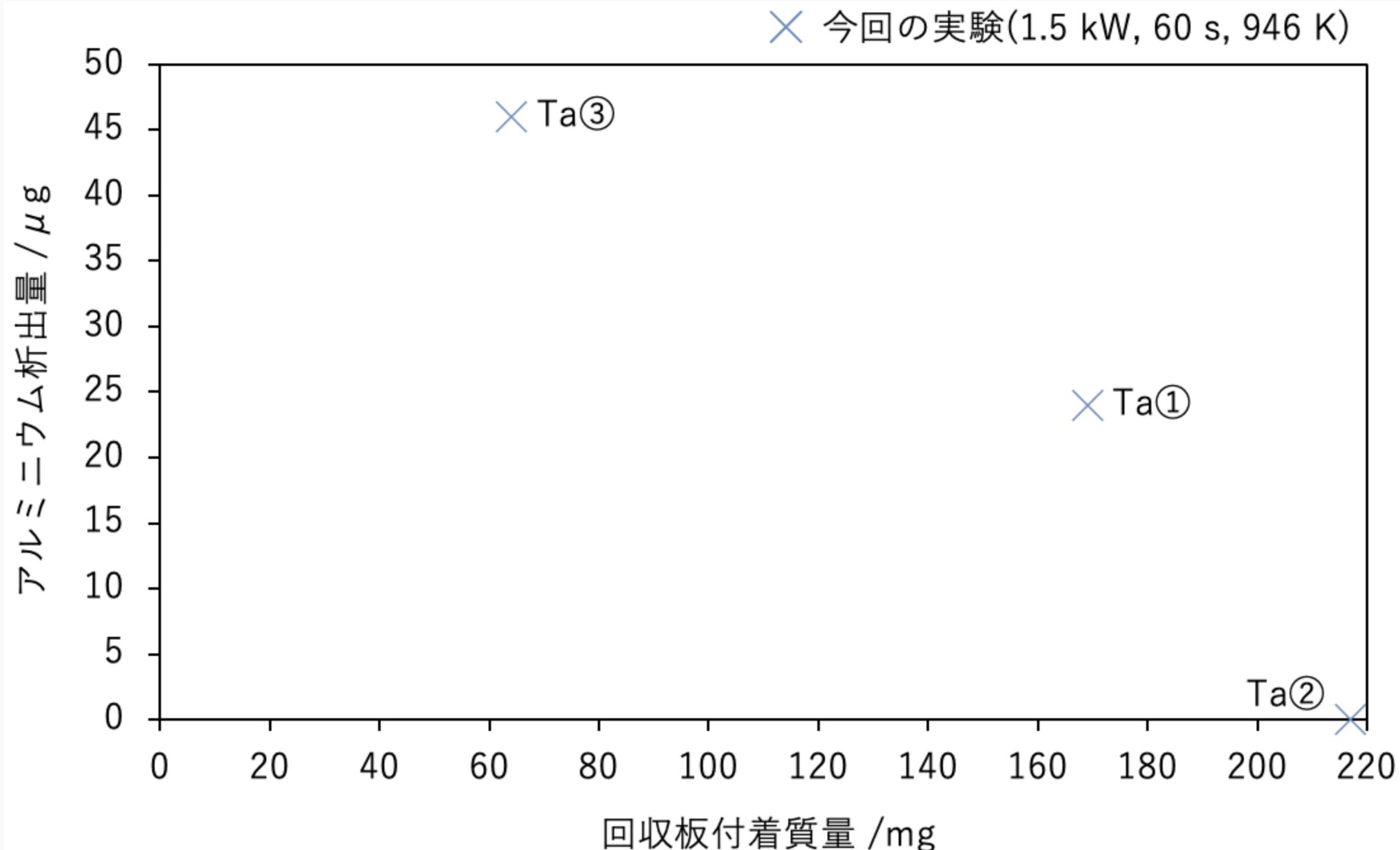
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# 2 of 3 experiments confirmed Al on the Ta plate

Results

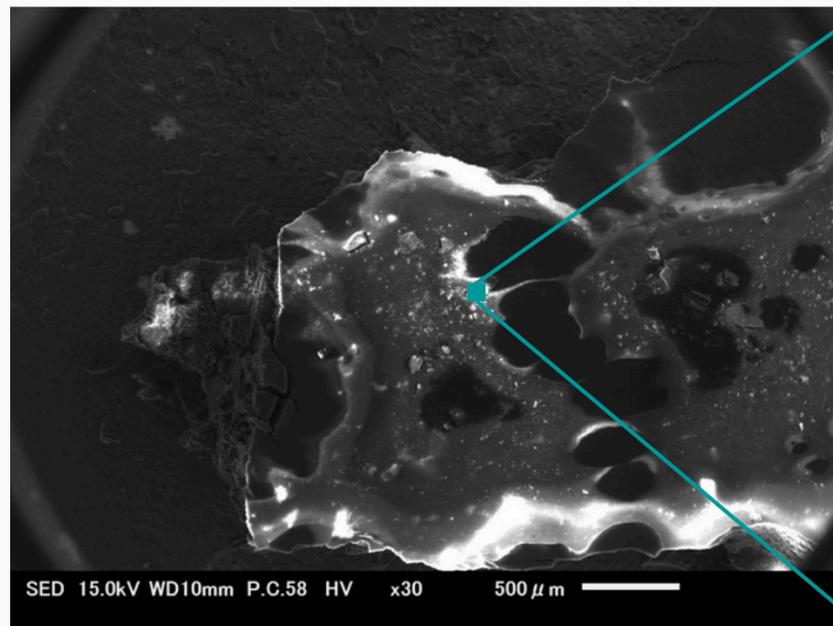
The deposition masses of Al were 26  $\mu\text{g}$  & 42  $\mu\text{g}$ , respectively



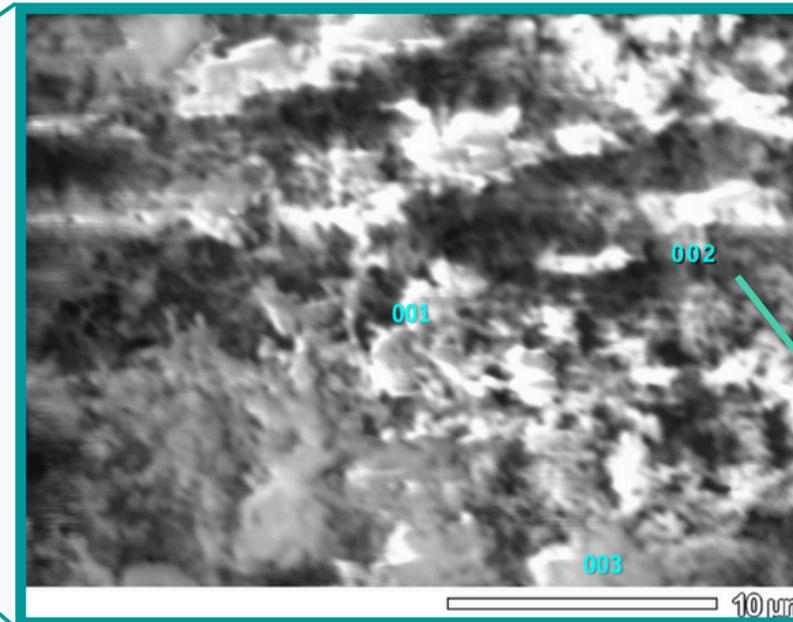
# Not oxygen-deficient alumina, but $\text{Al}_2\text{O}_3$ deposited Results

Atomic number ratio of Al & O on the plate was 2 : 3

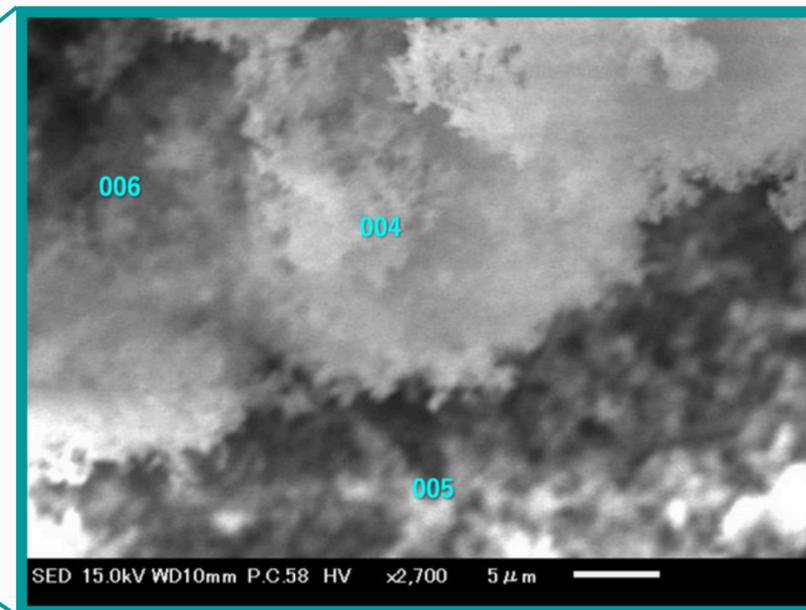
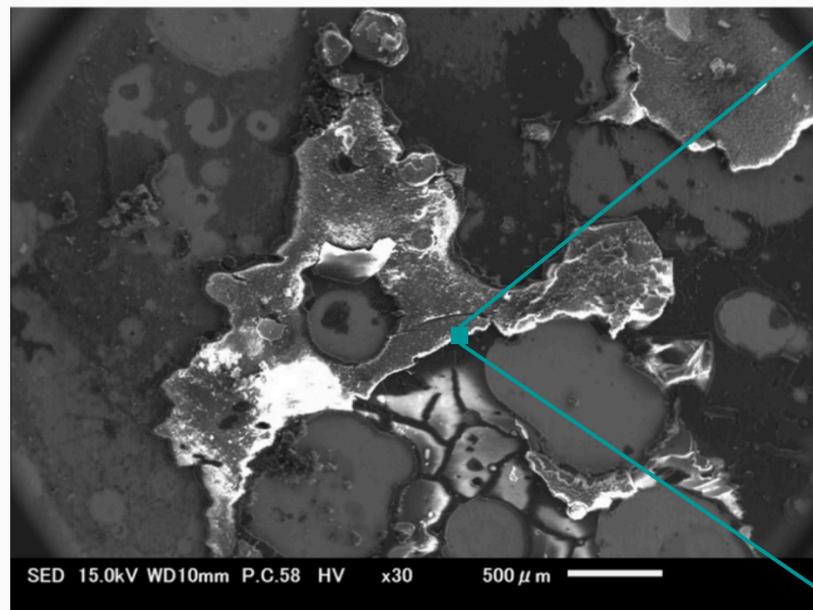
SEM



Enlarged SEM



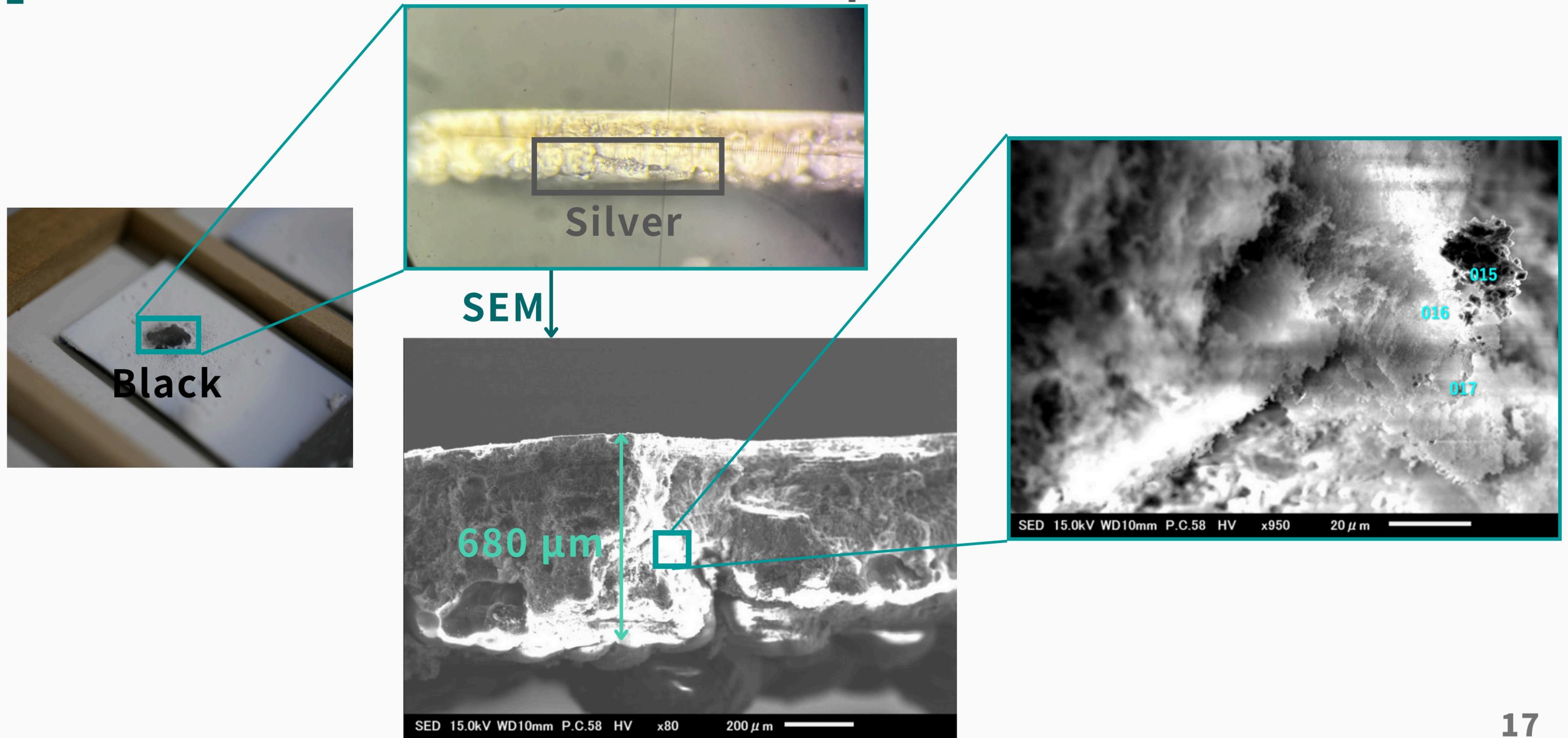
Example of EDX(002)



Atom	Atomic number /%	$\sigma$
Al	60.42	0.43
O	39.58	0.30
Other	0.0	-

# Even looked like black or silver, it was $\text{Al}_2\text{O}_3$

Al & O ratio of the black & silver parts were also 2 : 3



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# Conclusion & Future work

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- Conclusion
- Future work

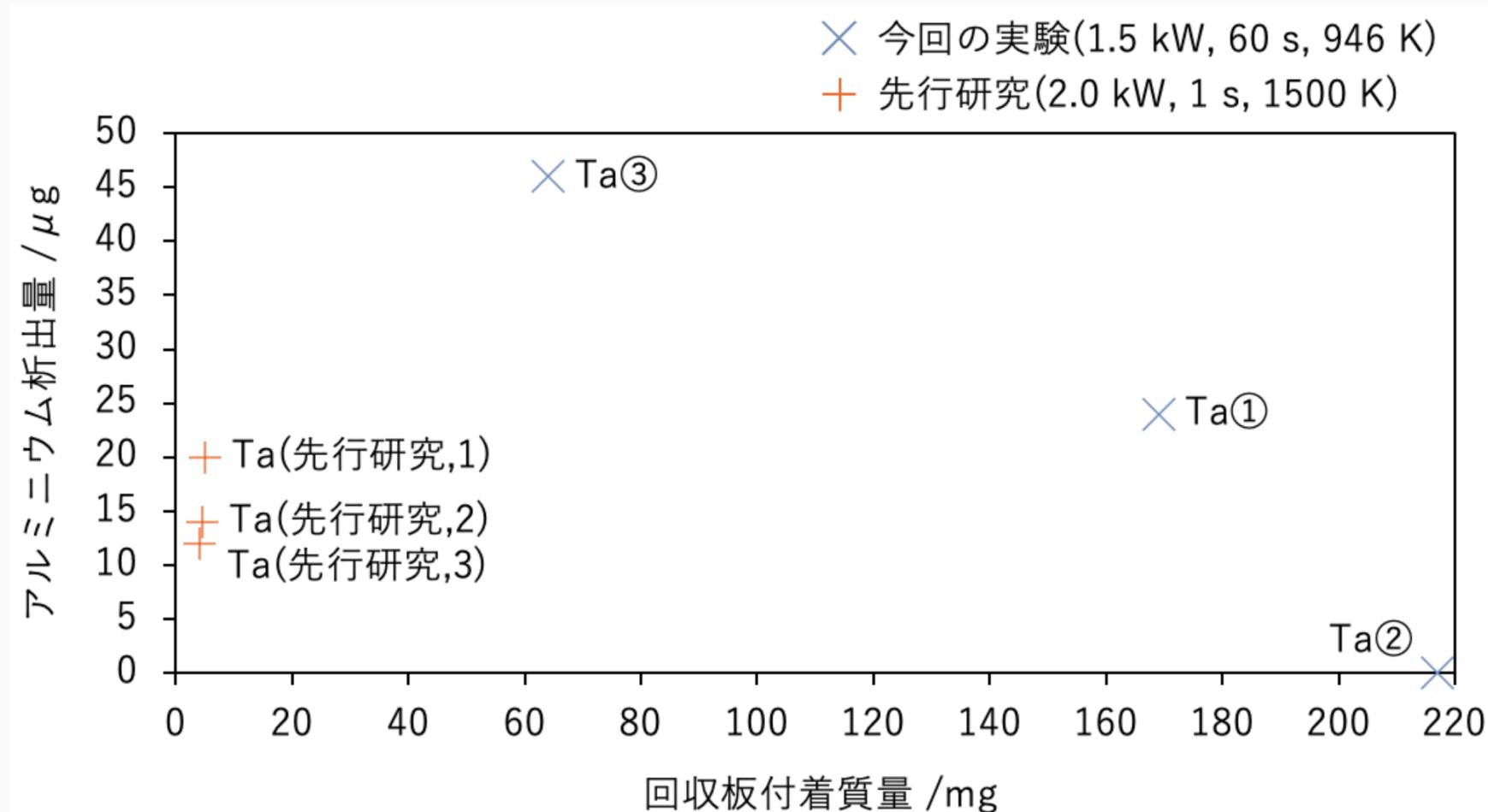
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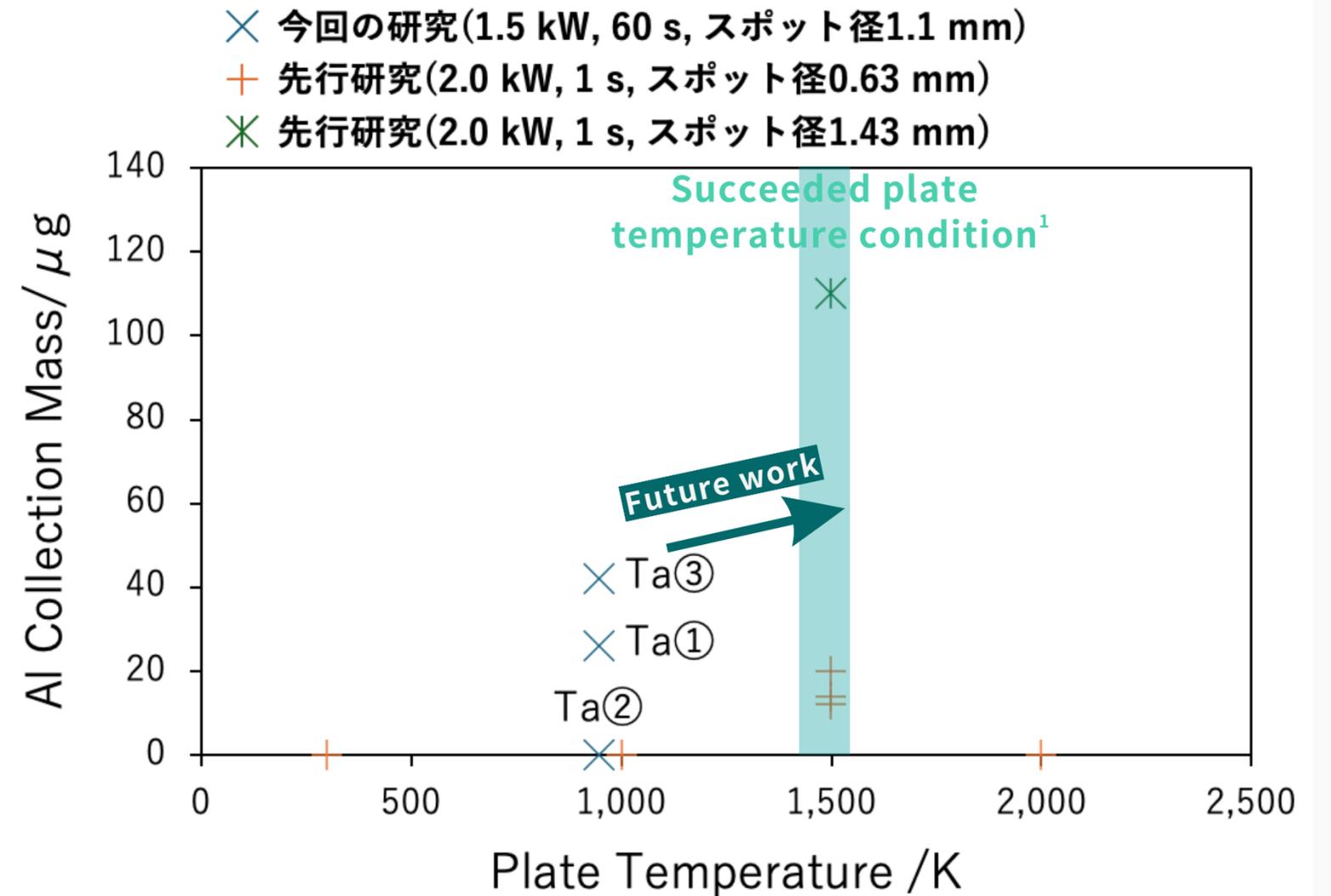
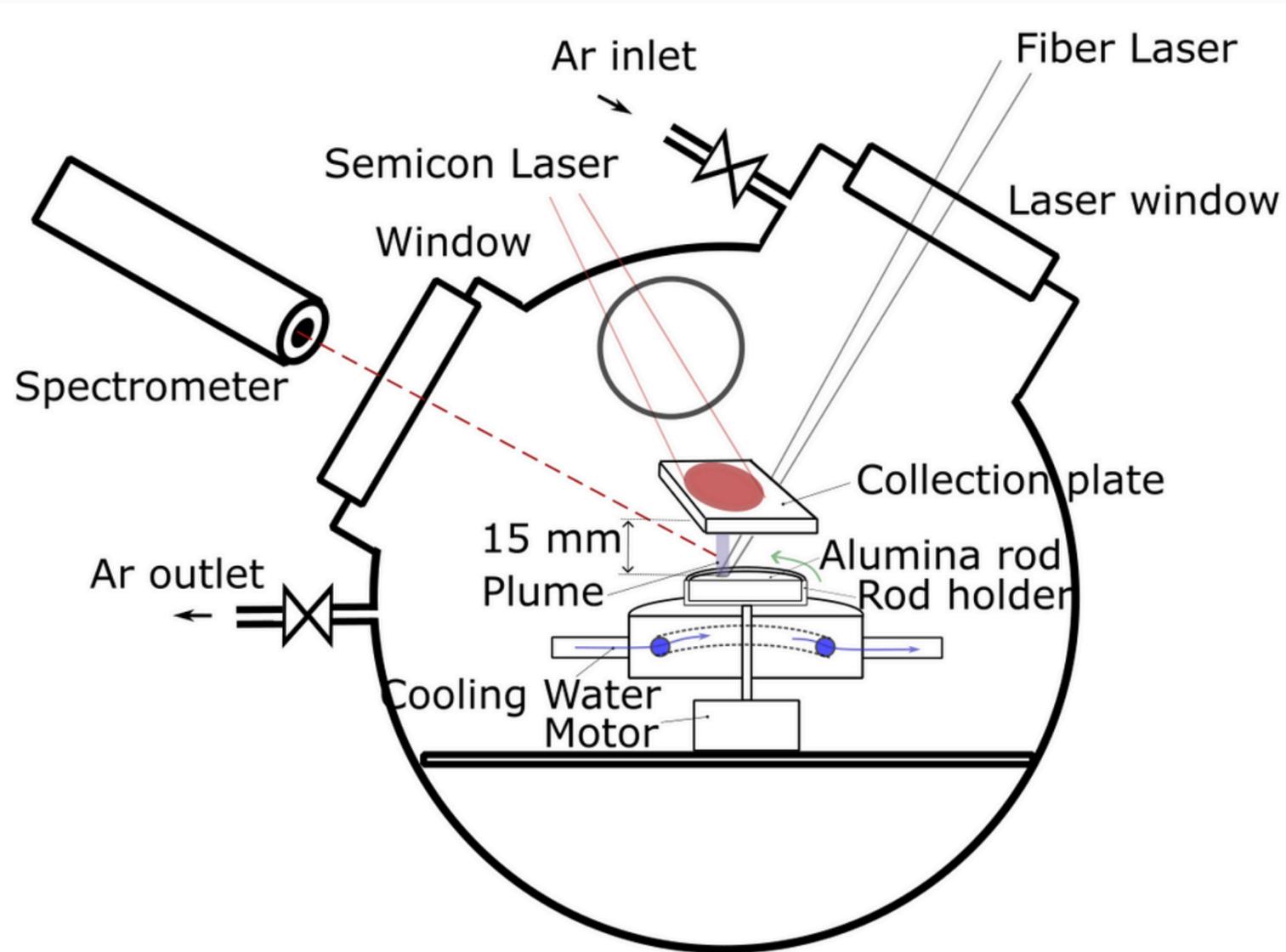
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## 3 Experiments with ~1000 K Ta plates were conducted

- 2 of 3 experiments confirmed the existence of Al, **24  $\mu\text{g}$** , **46  $\mu\text{g}$**  respectively
- High adhesion mass(**64~217 mg**) & Thick adhesion layer(**680  $\mu\text{m}$  ~**) were achieved
- No oxygen-deficient alumina was confirmed



## Experiments with ~1500 K plates are planned



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**Thank you for your attention.**

**2/28 @Hamamatsu**

**Effect of electric potential on the adhesion rate of alumina particles to the plate in laser ablation**

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**+α**

# Appendix

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## What is laser ablation?

- Thermally dissociate and reduce Alumina by laser
- No Carbon, potentially high energy efficiency



- ISRU
- Middle energy efficiency



- Established
- Not ISRU



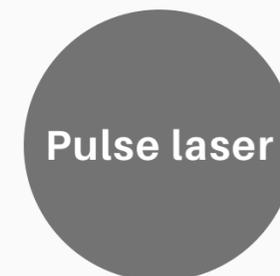
- ISRU
- Low energy efficiency

## CW laser is focused

- CW laser has advantage when it comes to sustainable useage
- Large ablation mass per unit time due to large total energy input



- Large ablation mass
- Low Al collection rate



- High Al collection rate
- Low productivity

# Adjusted condition for moderate preheating Setup & condition

Preheating power %



15%

13%

10%

0%



Too much preheating makes hemispheric surface

Moderate Preheating

Sudden temperature change causes spallation



Optimal laser intensity,  $0.32 \text{ GW/m}^2$ , was achieved in every experiments

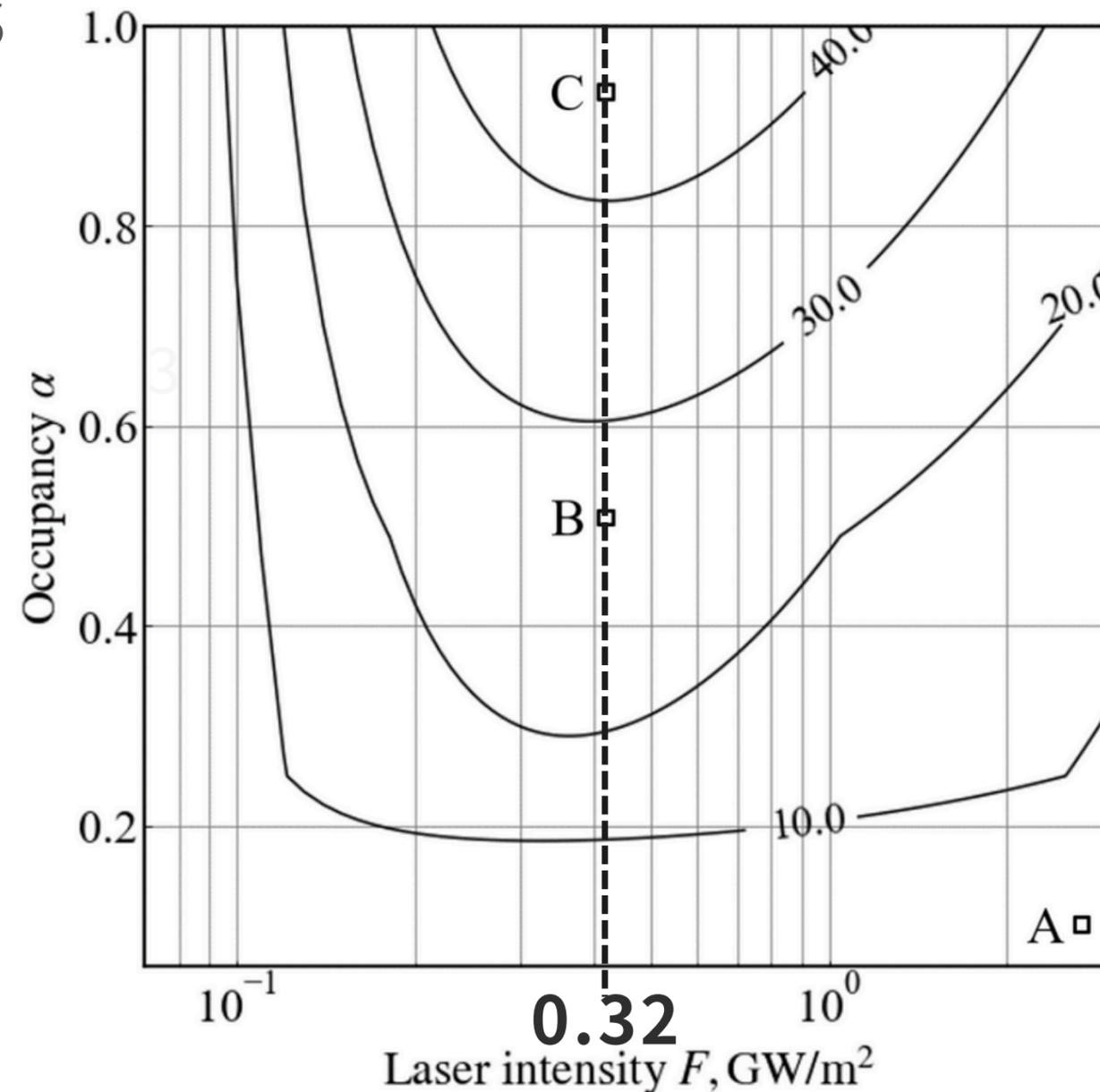
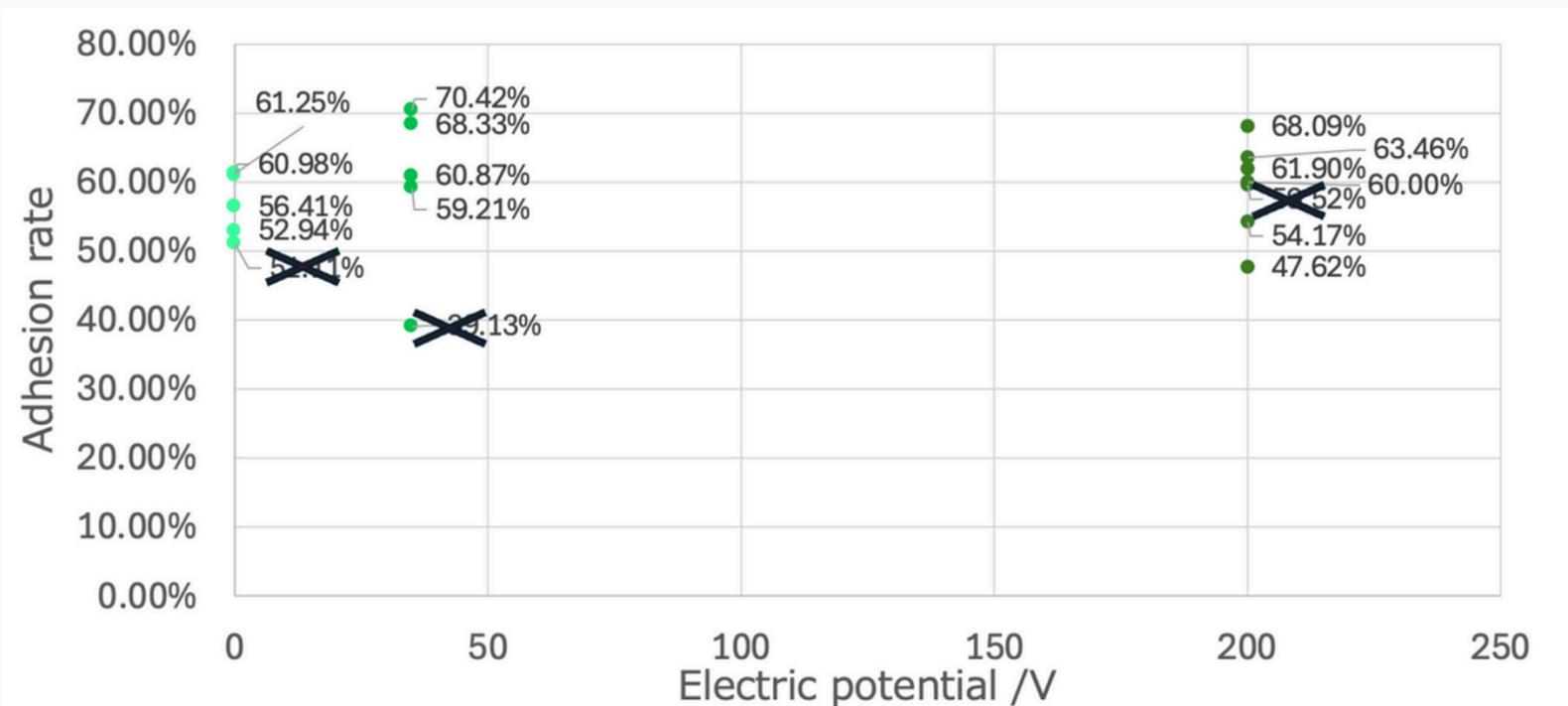


Figure 2-17 Ablation rate map with 2.0 kW laser power in various laser intensities and occupancies (i.e., the area ratio of laser spot to alumina rod surface).

# Applying electric potential didn't contribute to the thick $\text{Al}_2\text{O}_x$ layer

Review of my former research

The effect of electric potential on the adhesion rate, which might contribute to the thick  $\text{Al}_2\text{O}_x$  layer, was not confirmed



Average

